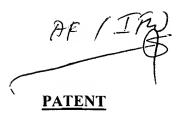


OK TO ENTER: /S.A./

01/14/2010



## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.:

10/594,635

Group Art Unit:

1793

Filing Date:

September 28, 2006

Examiner:

Shuangyi Abu Ali

Date: December 29, 2009

Applicant:

Yoshiharu OHTA et al.

Title:

SEMICONDUCTOR POLISHING COMPOSITION (As Amended)

Attorney Docket:

2691-000050/US

Customer Service Window Randolph Building 401 Dulany Street Alexandria, VA 22314

Mail Stop AF

## REQUEST FOR RECONSIDERATION

Sir:

In response to the Office Action mailed August 10, 2009, the shortened statutory period for reply being extended to January 10, 2010 by the attached Extension of Time, the following remarks are respectfully submitted.

A listing of the Claims begin on page 2 of this paper.

Remarks begin on page 4 of this paper.

	Claims remaining after Amendment		Highest number previously paid for		Present extra
Total	12	-	20	=	0
Independent	1	-	3	=	0